

## **REMARKS**

Favorable consideration and entry of record of the above claim amendment is respectfully requested.

Applicants observe that a Notice of Allowance has issued on November 29, 2005, but the issue fee payment has not been made.

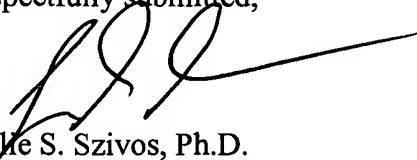
Applicants have amended Claim 19 to correct certain clerical errors therein. Specifically, the sentence “b) doping one or more other regions of said remaining portion of said wafer according to another set of doping variables, wherein one or more previously doped first regions and any remaining portion of said wafer is prevented from being doped.” in Claim 19 (page 5 of the Response dated June 17, 2005) should have been struck-through; and the sentence “patterning said first layer of photoresist to expose one or more first regions of said wafer, where remaining portions of said wafer are protected by a first patterned photoresist;” in Claim 19 (page 5 of the Response dated June 17, 2005) should have been underlined.

Applicant's further point out that the Response dated June 17, 2005 correctly recites the steps of Claim 19 in the Remarks section on page 10, the second paragraph.

Therefore, applicants respectfully submit that the above amendments merely embody formal changes in Claim 19 without changing the scope thereof.

In view of the foregoing, favorable consideration of the above amendments and entry thereof in the record of the present application is respectfully solicited.

Respectfully submitted,

A handwritten signature in black ink, appearing to be 'L. Szivos', written over the printed name.

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Enclosures